

# Changhong Yang

## List of Publications by Year in descending order

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73  
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1,810  
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331642

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73  
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#	ARTICLE	IF	CITATIONS
1	Excellent Energy Storage Performance in Bi(Fe <sub>0.93</sub> Mn <sub>0.05</sub> Ti <sub>0.02</sub> )O <sub>3</sub> Modified CaBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> Thin Film by Adjusting Annealing Temperature. <i>Nanomaterials</i> , 2022, 12, 730.	4.1	6
2	Coexistence of giant positive and large negative electrocaloric effects in lead-free ferroelectric thin film for continuous solid-state refrigeration. <i>Nano Energy</i> , 2021, 88, 106222.	16.0	13
3	4-inch Ternary BiFeO <sub>3</sub> /BaTiO <sub>3</sub> /SrTiO <sub>3</sub> Thin Film Capacitor with High Energy Storage Performance. <i>ACS Energy Letters</i> , 2021, 6, 3873-3881.	17.4	39
4	Flexible Lead-Free Ba <sub>0.5</sub> Sr <sub>0.5</sub> TiO <sub>3</sub> /0.4BiFeO <sub>3</sub> -0.6SrTiO <sub>3</sub> Dielectric Film Capacitor with High Energy Storage Performance. <i>Nanomaterials</i> , 2021, 11, 3065.	4.1	12
5	Flexible Lead-Free Perovskite Oxide Multilayer Film Capacitor Based on (Na <sub>0.8</sub> K <sub>0.2</sub> ) <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> /Ba <sub>0.5</sub> Sr <sub>0.5</sub> (Ti <sub>0.5</sub> Bi <sub>0.5</sub> ) <sub>0.5</sub> O <sub>3</sub> High-Performance Dielectric Energy Storage. <i>Advanced Energy Materials</i> , 2020, 10, 1904229.	16.0	84
6	Bendable Bi(Fe <sub>0.95</sub> Mn <sub>0.05</sub> )O <sub>3</sub> ferroelectric film directly on aluminum substrate. <i>Journal of Alloys and Compounds</i> , 2020, 827, 154381.	5.5	3
7	Flexible lead-free BFO-based dielectric capacitor with large energy density, superior thermal stability, and reliable bending endurance. <i>Journal of Materiomics</i> , 2020, 6, 200-208.	5.7	43
8	Toward Multifunctional Electronics: Flexible NBT-Based Film with a Large Electrocaloric Effect and High Energy Storage Property. <i>ACS Applied Materials &amp; Interfaces</i> , 2020, 12, 6082-6089.	8.0	42
9	Energy storage performance of flexible NKBT/NKBT-ST multilayer film capacitor by interface engineering. <i>Nano Energy</i> , 2020, 74, 104862.	16.0	84
10	Flexible, Temperature-Stable, and Fatigue-Endurable PbZr <sub>0.52</sub> Ti <sub>0.48</sub> O <sub>3</sub> Ferroelectric Film for Nonvolatile Memory. <i>Advanced Electronic Materials</i> , 2019, 5, 1900443.	5.1	25
11	Design of an all-inorganic flexible Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> -based film capacitor with giant and stable energy storage performance. <i>Journal of Materials Chemistry A</i> , 2019, 7, 22366-22376.	10.3	62
12	Flexible, Temperature-Resistant, and Fatigue-Free Ferroelectric Memory Based on Bi(Fe <sub>0.93</sub> Mn <sub>0.05</sub> Ti <sub>0.02</sub> )O <sub>3</sub> Thin Film. <i>ACS Applied Materials &amp; Interfaces</i> , 2019, 11, 12647-12655.	8.0	67
13	Fatigue-Free and Bending-Endurable Flexible Mn-Doped Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> /BaTiO <sub>3</sub> /BiFeO <sub>3</sub> Film Capacitor with an Ultrahigh Energy Storage Performance. <i>Advanced Energy Materials</i> , 2019, 9, 1803949.	19.5	165
14	Study on leakage current, ferroelectric and dielectric properties of BFMO thin films with different bismuth contents. <i>Journal of Materials Science: Materials in Electronics</i> , 2019, 30, 7704-7710.	2.2	7
15	Crystal structure, infrared spectra and microwave dielectric properties of novel extra low-temperature fired Eu <sub>2</sub> Zr <sub>3</sub> (MoO <sub>4</sub> ) <sub>9</sub> ceramics. <i>Journal of the European Ceramic Society</i> , 2019, 39, 1127-1131.	5.7	111
16	Effects of Nd <sup>3+</sup> -substitution for Bi-site on the leakage current, ferroelectric and dielectric properties of Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> thin films. <i>Ceramics International</i> , 2018, 44, 6330-6336.	4.8	39
17	Thickness-dependent ferroelectric and dielectric behaviors for Ni-doped Na <sub>0.05</sub> Bi <sub>0.05</sub> TiO <sub>3</sub> film derived by chemical solution deposition. <i>Journal of Materials Science: Materials in Electronics</i> , 2018, 29, 11039-11044.	2.2	5
18	Comparative study on energy storage performance of Na <sub>0.5</sub> Bi <sub>0.5</sub> (Ti,W,Ni)O <sub>3</sub> thin films with different bismuth contents. <i>Ceramics International</i> , 2018, 44, 9643-9648.	4.8	13

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19	The microstructure, energy storage and dielectric behaviours of (Ti,Zn)-doped $\text{Bi}_{0.97}\text{Nd}_{0.03}\text{FeO}_3$ thin films. <i>Materials Technology</i> , 2018, 33, 10-15.	3.0	5
20	Tailoring structural and electrical properties of A-site nonstoichiometric $\text{Na}_{0.5}\text{Bi}_{0.5}(\text{Ti}_{0.97}\text{Ni}_{0.03})\text{O}_3$ ferroelectric films deposited on $\text{LaNiO}_3(100)/\text{Si}$ substrate. <i>Ceramics International</i> , 2018, 44, 22406-22411.	4.8	3
21	Effect of donor W and acceptor Ni codoping at Ti site on the structure and electrical properties of $\text{Na}_{0.5}\text{Bi}_{0.5}\text{TiO}_3$ thin film. <i>Ceramics International</i> , 2018, 44, 15236-15242.	4.8	2
22	Design of magnetic-fluorescent based nanosensor for highly sensitive determination and removal of $\text{Hg}^{2+}$ . <i>Ceramics International</i> , 2018, 44, 9746-9752.	4.8	11
23	Enhanced energy storage property and dielectric tunability of $\text{Na}_{0.5}\text{Bi}_{0.5}(\text{Ti},\text{W},\text{Ni})\text{O}_3$ thin film on $\text{Bi}(\text{Fe},\text{Mn})\text{O}_3$ buffered $\text{LaNiO}_3(100)/\text{Si}$ substrate. <i>Journal of Materials Science: Materials in Electronics</i> , 2018, 29, 14479-14486.	2.2	0
24	Superior dielectric tunability of high-valence $\text{W}^{6+}$ -doped $\text{Na}_{0.5}\text{Bi}_{0.5}\text{TiO}_3$ thin films. <i>Journal of Materials Science: Materials in Electronics</i> , 2017, 28, 1433-1437.	2.2	2
25	Enhanced dielectric tunability of W-doped $\text{Na}_{0.5}\text{Bi}_{0.5}\text{TiO}_3$ thin film by moderating the precursor solution concentration. <i>Journal of Materials Science: Materials in Electronics</i> , 2017, 28, 3042-3047.	2.2	1
26	Comparative study on dielectric behavior in fresh and aged $\text{Na}_{0.5}\text{Bi}_{0.5}(\text{Ti},\text{Fe},\text{W})\text{O}_3$ thin films. <i>Ceramics International</i> , 2017, 43, 7690-7694.	4.8	5
27	Effects of thickness on the structural, ferroelectric and dielectric properties of (Nb,Fe)-codoped $\text{Na}_{0.5}\text{Bi}_{0.5}\text{TiO}_3$ thin film. <i>Journal of Materials Science: Materials in Electronics</i> , 2017, 28, 17833-17838.	2.2	0
28	Large dielectric tunability of (Ce,Fe)-codoped (Ba,Sr) $\text{TiO}_3$ thin film annealed at low temperature. <i>Journal of Materials Science: Materials in Electronics</i> , 2017, 28, 11332-11337.	2.2	1
29	The microstructure, leakage current and dielectric behaviors of (Nd,Ti)-codoped $\text{BiFeO}_3$ thin films: effect of deposited substrate. <i>Journal of Materials Science: Materials in Electronics</i> , 2017, 28, 3423-3427.	2.2	0
30	The microstructure, insulating and dielectric characteristics of $\text{Na}_{0.5}\text{Bi}_{0.5}\text{TiO}_3$ thin films: role of precursor solution. <i>Journal of Materials Science: Materials in Electronics</i> , 2017, 28, 18057-18063.	2.2	3
31	Microstructure, leakage current and dielectric tunability properties of $\text{W}^{6+}:\text{Na}_{0.5}\text{Bi}_{0.5}\text{TiO}_3/\text{Fe}^{3+}:\text{Na}_{0.5}\text{Bi}_{0.5}\text{TiO}_3$ bilayered thin film. <i>Materials Technology</i> , 2016, 31, 860-864.		
32	Substrate-dependent ferroelectric and dielectric properties of Mn doped $\text{Na}_{0.5}\text{Bi}_{0.5}\text{TiO}_3$ thin films derived by chemical solution decomposition. <i>Journal of Alloys and Compounds</i> , 2016, 679, 133-137.	5.5	11
33	Effects of annealing temperature on the microstructure, ferroelectric and dielectric properties of W-doped $\text{Na}_{0.5}\text{Bi}_{0.5}\text{TiO}_3$ thin films. <i>Ceramics International</i> , 2016, 42, 12210-12214.	4.8	5
34	Low temperature sintering and microwave dielectric properties of $\text{CoZrNb}_2\text{O}_8$ ceramics with $\text{H}_3\text{BO}_3$ addition. <i>Journal of Materials Science: Materials in Electronics</i> , 2016, 27, 6564-6569.	2.2	7
35	Effect of $\text{H}_3\text{BO}_3$ on sintering behavior and microwave dielectric properties of monoclinic structure $\text{ZnZrNb}_2\text{O}_8$ ceramics. <i>Journal of Materials Science: Materials in Electronics</i> , 2016, 27, 8055-8061.	2.2	5
36	High ferroelectric performance of $\text{Bi}_{0.9}\text{La}_{0.1}\text{FeO}_3$ thick film by optimizing preparation precursor solution. <i>Journal of Sol-Gel Science and Technology</i> , 2016, 80, 174-179.	2.4	5

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37	Influence of precursor solution concentration on the microstructure, leakage current and dielectric tunability of Zn-doped Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> thin films prepared by metal organic decomposition. <i>Ceramics International</i> , 2016, 42, 12033-12037.	4.8	6
38	Effect of defect dipole-induced aging on the dielectric property of Fe <sup>3+</sup> -doped Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> thin film. <i>Ceramics International</i> , 2016, 42, 2876-2881.	4.8	10
39	Effects of Zn <sup>2+</sup> doping content on the structure and dielectric tunability of non-stoichiometric [(Na <sub>0.7</sub> K <sub>0.2</sub> Li <sub>0.1</sub> ) <sub>0.45</sub> Bi <sub>0.55</sub> ]TiO <sub>3</sub> +f <sup>-</sup> thin film. <i>Journal of Materials Science: Materials in Electronics</i> , 2016, 27, 2195-2200.	2.2	10
40	Microstructure, ferroelectric and dielectric properties in Nd and Ti co-doped BiFeO <sub>3</sub> thin film. <i>Journal of Sol-Gel Science and Technology</i> , 2016, 78, 559-565.	2.4	7
41	Microstructure, leakage current and dielectric tunability of Na <sub>0.5</sub> Bi <sub>0.5</sub> (Ti <sub>0.99</sub> Zn <sub>0.01</sub> )O <sub>3</sub> thin films: An annealing atmosphere-dependent study. <i>Ceramics International</i> , 2016, 42, 8744-8749.	4.8	2
42	Effects of single-coated layer thickness on the microstructure, leakage current and dielectric tunability of Na <sub>0.5</sub> Bi <sub>0.5</sub> (Ti,Zn)O <sub>3</sub> -f <sup>-</sup> thin films prepared by metal organic decomposition. <i>Journal of Alloys and Compounds</i> , 2016, 663, 659-663.	5.5	7
43	Structural, ferroelectric and dielectric properties of Na <sub>0.5</sub> Bi <sub>0.5</sub> (Ti <sub>0.98</sub> Fe <sub>0.02</sub> )O <sub>3</sub> thin films on different substrates. <i>Journal of Materials Science: Materials in Electronics</i> , 2016, 27, 776-780.	2.2	5
44	The structure, ferroelectric and dielectric properties of Na <sub>0.5</sub> Bi <sub>0.5</sub> (Ti <sub>0.98</sub> Mn <sub>0.02</sub> )O <sub>3</sub> thin film prepared by chemical solution decomposition. <i>Materials Technology</i> , 2015, 30, A172-A175.	3.0	2
45	Enhanced ferroelectric and dielectric properties of Nb <sup>5+</sup> -doped Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> thin film deposited under nitrogen annealing atmosphere. <i>Ceramics International</i> , 2015, 41, 10272-10275.	4.8	12
46	Na <sub>0.5</sub> Bi <sub>0.5</sub> (Ti <sub>0.98</sub> Zr <sub>0.02</sub> )O <sub>3</sub> thin film with improved performance by modifying annealing atmosphere and Zr doping content. <i>Journal of Alloys and Compounds</i> , 2015, 637, 315-320.	5.5	26
47	Enhanced electrical properties in Bi(Fe <sub>0.95</sub> Mn <sub>0.05</sub> )O <sub>3</sub> modified Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> thin film. <i>Materials Technology</i> , 2015, 30, 151-154.	3.0	5
48	Structural, ferroelectric, and dielectric properties of bilayered Na <sub>0.5</sub> Bi <sub>0.5</sub> (Ti <sub>0.98</sub> Zr <sub>0.02</sub> )O <sub>3</sub> /Na <sub>0.5</sub> Bi <sub>0.5</sub> (Ti <sub>0.98</sub> Fe <sub>0.02</sub> )O <sub>3</sub> thin films prepared by metal organic decomposition. <i>Ceramics International</i> , 2015, 41, 859-863.	4.8	3
49	EFFECTS OF PRECURSOR SOLUTION MODIFICATION ON THE CRYSTALLINITY AND ELECTRICAL PROPERTIES OF Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> -BiFeO <sub>3</sub> BASED THIN FILM. <i>Surface Review and Letters</i> , 2014, 21, 1450064.	1.1	2
50	Dielectric tunability of highly (100)-oriented Fe-doped Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> thin film. <i>Ceramics International</i> , 2014, 40, 12989-12992.	4.8	6
51	Non-lead Ce: Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> -BiFeO <sub>3</sub> solid solution thin film with significantly reduced leakage current and large polarization. <i>Ceramics International</i> , 2014, 40, 4753-4757.	4.8	8
52	Effects of annealing temperature on the microstructure, electrical properties of Fe-doped Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> thin films. <i>Journal of Alloys and Compounds</i> , 2014, 586, 683-687.	5.5	15
53	Preparation of perovskite Fe-doped Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> thin film from polyethylene glycol-modified solution precursor on LaNiO <sub>3</sub> /Si substrate. <i>Materials Letters</i> , 2013, 102-103, 109-111.	2.6	11
54	Preparation and electrical properties of Sm-doped Bi <sub>2</sub> Ti <sub>2</sub> O <sub>7</sub> thin films prepared on Pt (111) substrates. <i>Ceramics International</i> , 2013, 39, 1125-1128.	4.8	14

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55	Reduced leakage current, enhanced ferroelectric and dielectric properties in (Ce,Fe)-codoped Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> film. Applied Physics Letters, 2012, 100, .	3.3	57
56	Statistical mechanical origin of hysteresis in ferroelectrics. Journal of Applied Physics, 2012, 112, 034113.	2.5	4
57	Ferroelectric, ferromagnetic, and dielectric behaviors of (Na <sub>0.5</sub> Bi <sub>0.5</sub> ) <sub>0.98</sub> Ce <sub>0.02</sub> (Ti <sub>0.99</sub> Fe <sub>0.01</sub> )O <sub>3</sub> BiFe <sub>0.95</sub> Mn <sub>0.05</sub> O <sub>3</sub> solid-solution thin film. Materials Letters, 2012, 88, 54-56.	2.6	9
58	Dielectric and ferroelectric properties of A-site non-stoichiometric Na <sub>0.5</sub> Bi <sub>0.5</sub> TiO <sub>3</sub> -based thin films. Materials Letters, 2012, 66, 86-88.	2.6	29
59	Comparative study on aging effect in BiFeO <sub>3</sub> thin films substituted at A- and B-sites. Applied Physics Letters, 2011, 99, .	3.3	33
60	PREPARATION AND FERROELECTRIC PROPERTIES OF LEAD-FREE (Na <sub>0.5</sub> Bi <sub>0.5</sub> ) <sub>0.98</sub> Ce <sub>0.02</sub> (Ti <sub>0.99</sub> Fe <sub>0.01</sub> )O <sub>3</sub> BiFeO <sub>3</sub> FILMS (A = Na OR Tl) ON SiO <sub>2</sub> /Si(100) SUBSTRATE	3.3	33
61	Large Piezoelectric Coefficient in Tb-Doped BiFeO <sub>3</sub> Films. Journal of the American Ceramic Society, 2010, 93, 948-950.	3.8	46
62	Enhanced Piezoelectric Properties of Epitaxial W-Doped BiFeO <sub>3</sub> Thin Films. Applied Physics Express, 2010, 3, 101501.	2.4	26
63	Thickness effects of Bi <sub>3.5</sub> Nd <sub>0.5</sub> Ti <sub>3</sub> O <sub>12</sub> buffer layers on structure and electrical properties of BiFeO <sub>3</sub> films. Journal of Materials Science, 2009, 44, 3556-3560.	3.7	3
64	Preparation and ferroelectric properties of predominantly (100)-oriented SrBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> ferroelectric thin film on Pt(111)/TiO <sub>2</sub> /SiO <sub>2</sub> /Si(100) substrate. Journal of Materials Science: Materials in Electronics, 2009, 20, 113-116.	2.2	2
65	Aging-Induced Double Ferroelectric Hysteresis Loops and Asymmetric Coercivity in As-Deposited Bi <sub>0.95</sub> Zn <sub>0.05</sub> O <sub>3</sub> Thin Film. Journal of the American Ceramic Society, 2009, 92, 1610-1612.	3.8	28
66	Low-Temperature Fabrication and Enhanced Ferro- and Piezoelectric Properties of Bi <sub>3.7</sub> Nd <sub>0.3</sub> Ti <sub>3</sub> O <sub>12</sub> Films on Indium Tin Oxide/Glass Substrates. Journal of the American Ceramic Society, 2009, 92, 1556-1559.	3.8	15
67	Effects of annealing process and Mn substitution on structure and ferroelectric properties of BiFeO <sub>3</sub> films. Thin Solid Films, 2009, 517, 4497-4501.	1.8	61
68	Low leakage current and enhanced ferroelectric properties of Ti and Zn codoped BiFeO <sub>3</sub> thin film. Applied Physics Letters, 2008, 92, .	3.3	221
69	Effects of Bi <sub>2</sub> Ti <sub>2</sub> O <sub>7</sub> buffer layer on memory properties of BiFe <sub>0.95</sub> Mn <sub>0.05</sub> O <sub>3</sub> thin film. Applied Physics Letters, 2008, 93, 172906.	3.3	12
70	Enhanced ferroelectric properties of predominantly (100)-oriented CaBi <sub>4</sub> Ti <sub>4</sub> O <sub>15</sub> thin films on Pt-Ti-SiO <sub>2</sub> -Si substrates. Journal of Applied Physics, 2008, 103, 056109.	2.5	21
71	Ferroelectric properties, morphologies, and leakage currents of Bi <sub>0.97</sub> La <sub>0.03</sub> FeO <sub>3</sub> thin films deposited on indium tin oxide/glass substrates. Journal of Applied Physics, 2008, 104, .	2.5	33
72	PREPARATION AND CHARACTERISTICS OF Sm-DOPED Bi <sub>2</sub> Ti <sub>2</sub> O <sub>7</sub> THIN FILMS. Surface Review and Letters, 2007, 14, 147-150.	1.1	3

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73	Effects of Gd substitution on structure and ferroelectric properties of BiFeO <sub>3</sub> thin films prepared using metal organic decomposition. Applied Physics Letters, 2007, 91, .	3.3	165